

4. (Amended) The micromachining surface treatment material of Claim 3, said surfactant is one of, or two or more of, a fatty amine ( $C_nH_{2n+1}NH_2$ ;  $[m]n=7$  [-] to 14), a fatty carboxylic acid ( $C_nH_{2n+1}COOH$ ;  $n = 5$  [-] to 11), or a fatty alcohol ( $C_nH_{2n+1}OK$ ;  $n = 6$  [-] to 12).

5. (Amended) A surface treatment method that removes a natural oxidation layer inside contact holes using the micromachining surface treatment material of [any one of Claims 1 to 3] Claim 1.

A' 6. (Amended) The surface treatment method of Claim 5, wherein [the diameter of the contact holes is less than or equal surface treatment method of Claim 5 or Claim 6, wherein] the contact holes open to an oxidation film.

7. (Amended) The surface treatment method of [any one of] Claim 5 [to Claim 7], wherein the oxidation film is a CVD type oxidation film.

8. (Amended) The surface treatment method of [any one of] Claim 5 [to Claim 7], wherein the oxidation film is a TEOS type oxidation film.

9. (New) The micromachining surface treatment material of Claim 2, containing a surfactant at 0.0001 to 1% by weight.

10. (New) A surface treatment method that removes a natural oxidation layer inside contact holes using the micromachining surface treatment material of Claim 2.

11. (New) A surface treatment method that removes a natural oxidation layer inside contact holes using the micromachining surface treatment material of Claim 3.

12. (New) The surface treatment method of Claim 10, wherein the contact holes open to an oxidation film.

A' 13. (New) The surface treatment method of Claim 11, wherein the contact holes open to an oxidation film.

14. (New) The surface treatment method of Claim 10, wherein the oxidation film is a CVD type oxidation film.

15. (New) The surface treatment method of Claim 11, wherein the oxidation film is a CVD type oxidation film.

16. (New) The surface treatment method of Claim 12, wherein the oxidation film is a CVD type oxidation film.

17. (New) The surface treatment method of Claim 13, wherein the oxidation film is a CVD type oxidation film.

18. (New) The surface treatment method of Claim 10, wherein the oxidation film is a TEOS type oxidation film.

19. (New) The surface treatment method of Claim 13, wherein the oxidation film is a TEOS type oxidation film.

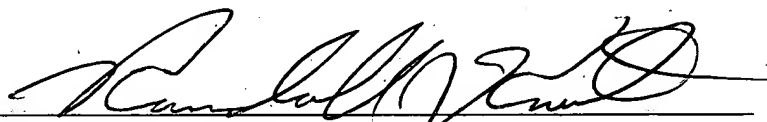
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IN THE ABSTRACT

Please replace the abstract on file with the attached  
ABSTRACT OF THE DISCLOSURE.

If the Examiner has any questions or comments that would speed prosecution of this case, he is invited to call the undersigned at 219/485-6001.

Respectfully submitted,

  
Randall J. Knuth  
Registration No. 34,644

RJK/jrc

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ABSTRACT OF THE DISCLOSURE

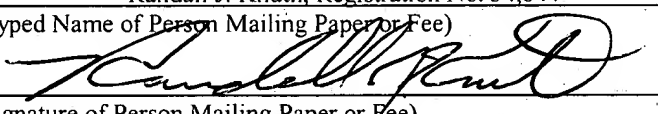
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